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Optical band gap and magnetic properties of unstrained EuTiO₃ films

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Phase-pure, stoichiometric, unstrained, epitaxial (001)-oriented EuTiO₃ thin films have been grown on (001) SrTiO₃ substrates by reactive molecular-beam epitaxy. Magnetization measurements show antiferromagnetic behavior with T_N =5.5 K, similar to bulk EuTiO₃. Spectroscopic ellipsometry measurements reveal that EuTiO₃ films have a direct optical band gap of 0.93 ± 0.07 eV. © 2009 American Institute of Physics. [DOI: 10.1063/1.3133351]

EuTiO₃ has many similarities to SrTiO₃ including being a quantum paraelectric ^{1,2} and a cubic structure (space group $Pm\overline{3}m$) with a lattice parameter of 3.905 Å at room temperature. ^{2–5} In contrast to the diamagnetic nature of SrTiO₃, bulk EuTiO₃ exhibits antiferromagnetic order at 5 K due to the localized 4f moments on the Eu²⁺ site. ^{6,7} While SrTiO₃ is on the brink of being ferroelectric, EuTiO₃ is on the brink of being simultaneously ferroelectric and ferromagnetic. ^{8,9}

With its nearly identical lattice constant, SrTiO₃ has been shown to be an excellent substrate for the growth of epitaxial EuTiO₃ films. ¹⁰ Significantly different structural and magnetic properties, however, have been reported for $EuTiO_3$ films. As-grown $EuTiO_{3-\delta}$ films by pulsed-laser deposition (PLD) on (001) SrTiO3 substrates exhibit expanded out-of-plane spacings (0.4%-2% longer than bulk EuTiO₃)^{10–13} and are *ferromagnetic* with a Curie temperature of about 5 K. 11,12 Biaxial strain has been predicted to cause significant changes to the properties of EuTiO₃, including the emergence of a multiferroic ground state where EuTiO₃ is simultaneously ferromagnetic and ferroelectric at sufficiently high values of strain ($\geq 1.2\%$ biaxial compression). As the lattice constant of EuTiO₃ is identical to that of SrTiO₃ within <0.1%, the epitaxial growth of fully oxygenated EuTiO₃ films is not expected to yield ferromagnetic films or films with extended lattice constants. The negligible (<0.5%) variation in the cubic lattice constant of oxygen deficient EuTiO_{3-δ} over its wide single phase field, ^{14,15} up to the EuTiO_{2.5} limit¹⁴ of the perovskite EuTiO_{3- δ} structure, is insufficient to explain the 2% elongation observed in epitaxial EuTiO_{3- δ} films grown on (001) SrTiO₃ by PLD. ^{11–13}

One possibility is that the ferromagnetism observed in epitaxial EuTiO₃ films on SrTiO₃ arises from extrinsic effects. Extrinsic effects are known to occur in thin films, particularly for deposition technologies involving energetic spe-

To clarify the different ferromagnetic orderings reported for bulk and thin film EuTiO₃, the growth of high crystalline quality epitaxial thin films is desired. Reactive molecular-beam epitaxy (MBE) has been successful in the preparation of high quality thin films of related oxides including SrTiO₃, BaTiO₃, and EuO by optimizing the independent growth parameters including oxygen partial pressure. ¹⁹ In this letter, we report the epitaxial growth of unstrained EuTiO₃ thin films on (001) SrTiO₃ by reactive MBE and discuss the resulting structure composition, magnetic ordering, band gap, and complex dielectric function.

EuTiO $_3$ films were grown on buffered-HF treated SrTiO $_3$ (001) substrates 20 in a reactive MBE system. Molecular beams of europium and titanium were generated using a conventional effusion cell and a Ti-BallTM titanium sublimation pump, 21 respectively. Europium and titanium were codeposited onto the substrate under an oxygen background partial pressure of 3×10^{-8} Torr at a substrate temperature of 650 °C. A thin layer ($\sim \! 10$ nm thick) of amorphous silicon was deposited on some of the EuTiO $_3$ films to prevent oxidation of Eu $^{2+}$ into Eu $^{3+}$ upon exposure to air.

The structural perfection of a silicon-capped, 22 nm thick EuTiO₃ film grown on (001) SrTiO₃ was characterized by x-ray diffraction (XRD). As Fig. 1(a) shows, an out-of-plane θ -2 θ scan reveals phase-pure, epitaxial (001)-oriented EuTiO₃. The 00*l* reflections from the film are buried by the high intensity of the substrate 00*l* reflections because the lattice constant of EuTiO₃ is equal to that of SrTiO₃ (a = 3.905 Å).^{3,4} An ω rocking curve around the 002 peak (not

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icularly for deposition technologies involving energetic s

cies, which can induce defects. For example, some homoepitaxial SrTiO₃ films grown by PLD have been reported to be ferroelectric ¹⁶ in striking contrast to the intrinsic properties of SrTiO₃, which is not ferroelectric at any temperature. ¹ Homoepitaxial SrTiO₃ films grown by PLD are also known to exhibit lattice spacings that deviate significantly from the SrTiO₃ substrates they are grown on. ^{17,18} Such issues lead to the question of what the intrinsic properties of unstrained EuTiO₃ films really are.

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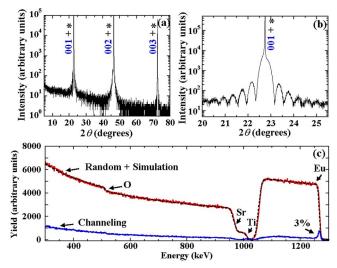


FIG. 1. (Color online) (a) θ -2 θ XRD scans of a silicon-capped, 22 nm thick (001)-oriented EuTiO₃ on (001) SrTiO₃. Substrate peaks are marked with an asterisk (*). (b) A close-up of the 001 peak, showing thickness fringes. (c) RBS random and channeling spectra of an uncapped, 200 nm thick EuTiO₃ film on (001) SrTiO₃ with the simulated curve (dashed line). The simulated curve gives a thickness of 200 nm and a Eu:Ti ratio of 1:1.

shown) also reveals a single reflection from the SrTiO₃ substrate. Clear thickness fringes corresponding to a film thickness of $22\pm1\,$ nm are observed from a high-resolution θ - 2θ scan of the 001 EuTiO₃+001 SrTiO₃ peak in Fig. 1(b). These Kiessig fringes indicate the presence of a lattice-matched unstrained EuTiO₃ film with a smooth film surface. Figure 1(c) shows the RBS and channeling spectra of an uncapped, 200 nm thick EuTiO₃ film utilizing He⁺ ions with an energy of 1.4 MeV. The overlaid results of a RUMP²² simulation with the RBS spectra reveal a Eu:Ti ratio of 1:1, indicating that the film composition is stoichiometric within experimental error ($\pm5\%$). The low channeling minimum χ_{min} =3% confirms the good crystallinity of the film.

Figures 2(a) and 2(b) show high-angle annular dark field (HAADF) images from a scanning transmission electron microscope (STEM) of the same film analyzed in Fig. 1(a). The entire epitaxial heterostructure is observed, and the interface between the film and the substrate is atomically sharp. The valence state of europium in the same film was analyzed by x-ray absorption spectroscopy (XAS) at beamline 4-ID-C of the Advanced Photon Source. The XAS data in Fig. 2(c) show a behavior consistent with europium in the 2+ valence state. Comparison with calculations allows us to determine that Eu³⁺ is below the detectable level, and from this we can confirm that the film contains >90% Eu²⁺. 23

Contrary to prior reports of ferromagnetic behavior in PLD-grown EuTiO_{3- δ} films, ^{11,12} the MBE-grown EuTiO_{3- δ} films exhibit a clear magnetic transition with a small magnetic response consistent with antiferromagnetic order. Figure 3 shows the temperature dependence of the magnetization (after subtracting the diamagnetic contribution of the SrTiO₃ substrate) as a function of film thickness measured using a superconducting quantum interference device magnetometer (Quantum Design MPMS). Due to the possible formation of a ferromagnetic europium silicate layer (e.g., Eu₂SiO₄)¹⁴ during silicon deposition on top of EuTiO₃ films, uncapped films were measured in Fig. 3. For 200, 100, and 50 nm thick films, an antiferromagnetic transition occurs at 5.5 K, which corresponds to the antiferromagnetic transition

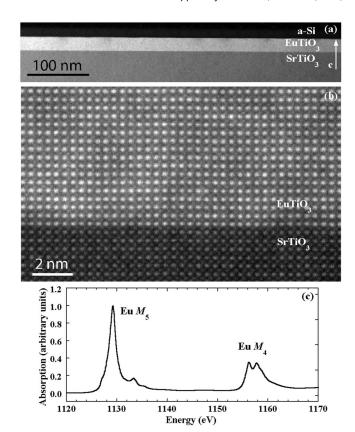


FIG. 2. (a) HAADF STEM image of the same film analyzed in Fig. 1(a). (b) Atomically sharp interface of the $EuTiO_3$ film and the $SrTiO_3$ substrate. (c) $Eu\ M_{4.5}$ edges from XAS, showing the valence state of europium is 2+.

temperature T_N of bulk EuTiO₃.^{6,7} The low field dependence of magnetization for the same 200 nm thick EuTiO₃ film at 1.8 K is shown in the inset of Fig. 3. The spin-flop transition is indicated by the change of curvature at around 1.5 kOe and no remnant magnetization is observed. The saturation magnetizations (not shown) measured for all films analyzed in Fig. 3 at 1.8 K under a high magnetic field (>10 kOe) are 6.7 ± 0.5 Bohr magnetic moment of a Eu²⁺ ion (7 μ_B /Eu). The bulk-like antiferromagnetic behavior of MBE-grown unstrained EuTiO₃ films in combination with RBS and XAS analyses confirms that the MBE-grown films are stoichiometric and have the desired europium valance state. These results support the notion that our growth conditions allow us to investigate the intrinsic magnetic proper-

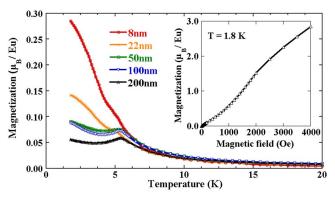


FIG. 3. (Color online) Field-cooled magnetization of 8, 22, 50, 100, and 200 nm thick, uncapped EuTiO₃ films at H=100 Oe, showing an antiferromagnetic ordering with T_N =5.5 K. (inset) Field dependence of the magnetization for the same 200 nm thick EuTiO₃ film at 1.8 K.

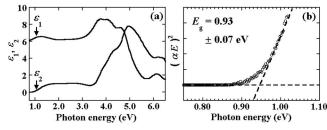


FIG. 4. (a) Dielectric function spectra of an uncapped, \sim 53 nm thick EuTiO₃ film on (001) SrTiO₃ over a spectral range from 0.75 to 6.5 eV. (b) Linear extrapolation of $(\alpha E)^2$ =0 to determine the direct band gap.

ties of EuTiO₃ films and that prior results^{11,12} are dominated by extrinsic effects.

The optical band gap of an uncapped, ~ 53 nm thick EuTiO₃ film grown on (001) SrTiO₃ was determined by spectroscopic ellipsometry. Room temperature ellipsometric spectra (in Δ and Ψ) were collected ex situ at three angles of incidence, $\Theta_i = 55^{\circ}$, 70° , and 85° , using a variableangle rotating-compensator multichannel spectroscopic ellipsometer^{24,25} over a spectral range from 0.75 to 6.5 eV. The complex dielectric function spectra $(\varepsilon = \varepsilon_1 + i\varepsilon_2)$ shown in Fig. 4(a) were extracted using a least-squares regression analysis and an unweighted root mean square error function²⁶ to fit the experimental spectra to a four-medium optical model consisting of a semi-infinite SrTiO₃ substrate/ bulk film/surface roughness/air ambient structure. The free parameters correspond to the bulk thickness of the EuTiO₃ film, surface roughness, and a parametrization of the EuTiO₃ dielectric function, consisting of five Gaussian²⁷ oscillators representing the critical point features at energies greater than 3.0 eV, two Tauc-Lorentz oscillators²⁸ sharing a common Tauc gap below 3.0 eV, a high energy Sellemeier oscillator, ²⁹ and a constant additive term to ε_1 represented by ε_{∞} . The optical properties of the surface roughness layer are Bruggeman effective represented by a approximation³⁰ consisting of a 50% bulk film/50% void mixture. After obtaining a bulk layer thickness of 54.2 ± 1.3 nm and a surface roughness thickness of 2.3 ± 0.4 nm from the parametrized model, the complex dielectric function spectra were directly obtained by numerical inversion of the $\Theta_i = 70^{\circ}$ spectra.

The absorption coefficient α is obtained from ϵ . The onset of optical absorption is observed at $0.85\pm0.02\,$ eV for the EuTiO $_3$ film. The direct or indirect band gap may be determined from a linear extrapolation of $(\alpha E)^2$ or $(\alpha E)^{1/2}$, respectively. An additional criteria for identification of the indirect band gap involves the presence of two distinct slopes in $(\alpha E)^{1/2}$, which is not observed and indicates that EuTiO $_3$ is a direct band gap material. The direct band gap, shown in Fig. 4(b), is at $0.93\pm0.07\,$ eV. These values are considerably higher than the E_g =0.4 eV gap between the filled europium f-level and the empty titanium d-level predicted by density functional calculations within the GGA+U approximation using an appropriate U-J=5 eV on the europium f orbital determined by Fennie and Rabe. 8

A comparison between the dielectric functions of EuTiO₃ and SrTiO₃ shows that each material shares common high energy critical point features, but exhibits different behavior below the indirect band gap of SrTiO₃ at 3.2 eV. Below 3.2 eV, EuTiO₃ continues to exhibit substantial absorption and shows two additional critical point features at

1.44 eV and 2.80 eV, which are not present in SrTiO₃. These features mirror comparisons between the absorption spectra of SrO³³ and EuO,³⁴ and can be attributed to interactions between f- and d-level states.

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